

Notice of References Cited	Application/Control No. 10/599,252		Applicant(s)/Patent Under Reexamination ALIVISATOS ET AL.	
	Examiner G. NAGESH RAO		Art Unit 1714	Page 1 of 2

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*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
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